Optimizations of transverse projected emittance at the photo-injector test facility at DESY, location Zeuthen

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1. Introduction

Linac based free-electron laser (FEL) light sources like the free-electron laser at DESY (FLASH) [1], the European X-ray free-electron laser (European XFEL) [2], the linac coherent light source (LCLS) at SLAC [3], the Spring-8 Compact SASE source (SCSS) X-FEL [4], the free-electron laser for multidisciplinary investigations (FERMI) at Elettra [5], and the Swiss free-electron laser (SwissFEL) [6] require electron beams of high quality for both, the transverse and longitudinal phase spaces. Research activities at the photo-injector test facility at DESY, location Zeuthen (PITZ) combine development, characterization, and optimization of photo-injector electron sources to produce electron beams with parameters yielding the requirements for FLASH and the European XFEL. Wavelength and gain of the self amplified spontaneous emission (SASE) FEL process are defined by peak current, energy spread, and transverse emittance of the electron beam for a certain undulator period and length. As an example, a nice overview on high gain FEL can be found in Ref. [7]. The peak current and energy spread are properties which can be improved during the
beam transport before the electron beam enters the undulator, e.g. by using accelerating structures or bunch compressors. On the contrary, the transverse emittance of the beam has to be optimized at the source since it cannot be improved anymore after the beam exits the injector which includes the gun and the next accelerating module except an emittance exchange system is installed downstream. The emittance exchange system can improve the transverse emittance but on the expense of the longitudinal emittance [8–10].

The required transverse slice emittance of an electron beam with a bunch charge of 1 nC at the undulator entrance of the European XFEL is 1.4 mm mrad. With some room for the degradation of the slice emittance from the gun to the undulator and some safety margin, a normalized projected transverse emittance of 0.9 mm mrad at the photo-injector exit is required [2]. Since the production of electron beams with such a small emittance is the most challenging research task at PITZ, a major part of the measurement program is devoted to the transverse emittance optimization. Experimental results of the projected transverse emittance from the setup in 2007 yielded a measured geometric mean emittance \[ \text{1.26} \pm \text{0.13 mm mrad} \] for a 100% rms phase space distribution [11].

There are several improvements and changes of the PITZ beam transport line compared to the setup in 2007 with the goal to improve the electron source properties and to extend the capability of the facility for beam characterization. Since this upgrade was significant, a new machine optimization became necessary. Measurement results with the improved setup, described in this paper, show the possibility to achieve and surpass the required projected transverse emittance for the European XFEL photo-injector.

### 2. PITZ setup and machine preparations

The PITZ setup in 2008–2009 (Fig. 1) consisted of a laser driven RF-gun, a normal conducting TESLA type booster cavity and various beam diagnostic systems. The main changes compared to the setup in 2007 included a new gun cavity, the installation of a new photocathode laser system, a position shift of the booster cavity, the installation of a new 180° dipole spectrometer with a corresponding dispersive section, the installation of quadrupole magnets, a position shift of emittance measurement systems corresponding to the shift of the booster cavity, and the modification of several diagnostic components i.e. improvement of TV and video systems, re-design of a diagnostic cross and a spectrometer dipole in the low energy section. More details of the upgrades in the PITZ beam line can be found in Refs. [12,13].

#### 2.1. Electron gun

The electron gun in the PITZ setup is a 1.6 cell L-band normal conducting RF cavity with a Cs₂Te photocathode located at the backplane of the cavity. The photocathodes are produced by INFN-LASA and have a high quantum efficiency and a long life time [14–16]. The RF-gun is powered by a 10 MW klystron via a coaxial RF coupler and has a resonance frequency of 1.3 GHz. The RF pulse length is up to 900 ms with a repetition rate of 10 Hz. The duty cycle is almost 1%. The gun is designed for an average power of up to 50 kW. It is surrounded by a main and a bucking solenoid magnet. The main solenoid is used to focus the beam to counteract the repulsion due to the space-charge force and to focus the beam at the entrance of the booster cavity, while the bucking solenoid is used to cancel the residual field of the main solenoid at the photocathode plane (see Ref. [11] and references therein). The new gun cavity (gun prototype 4.2), which was used in the setup described here, was designed with similar geometry to the previous gun [11] but with an improvement in the cooling system for operation with high RF peak power and long pulse trains. Low

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\[ \text{10 The geometric mean emittance is given as the geometric mean of the normalized transverse projected rms emittance averaged over the two transverse planes.} \]
level RF measurements and tuning of the gun cavity were performed after the fabrication was completed. The gun was mechanically tuned by slightly deforming the cavity end walls to reach the desired resonance frequency of 1.3 GHz at an operating temperature of 55 °C. The peak accelerating field at the cathode was tuned to be about 5% higher than the field at the center of the second cell [17].

The gun cavity’s interior surface was prepared using a dry-ice sublimation-impulse cleaning technique [18]. It includes several thermo-mechanical and chemical processes. This cleaning technique is able to clean a cavity surface by removing particles with a size down to 100 nm. By applying this cleaning technique to the RF-gun, a significant dark current reduction by a factor of 10 was achieved compared to the previous guns where high-pressure water rinsing was used [12,19]. The reduced amount of dark current improves the cathode lifetime for operation with high electric peak fields and allows lower vacuum pressures to be maintained during RF operation. After successful commissioning we demonstrated the required RF parameters for the injector of the European XFEL: an average RF power of 50 kW with an RF power of 7.1 MW, an RF pulse length of 700 μs and a repetition rate of 10 Hz [19].

2.2. Photocathode laser system

A new photocathode laser system was developed by the Max-Born Institute (MBI) and was installed at PITZ in 2008. The laser system is based on a diode pumped Yb:KGW laser oscillator, an Yb:YAG regenerative amplifier, and a two-stage Yb:YAG double pass amplifier [20]. It can produce laser pulse trains of up to 800 micro-pulses with 1 MHz frequency at 10 Hz repetition rate, which leads to a spacing of 1 μs between the pulses. The UV output pulses have a wavelength of 257 nm and an energy of ~10 μJ per micro pulse. Due to the high quantum efficiency (QE) of the Cs2Te cathode of 5–10%, not more than 100 nJ of laser energy is sufficient to produce high charge electron beams of 1 nC. The large overlap is required for transverse shaping and as a reserve in case of QE degradation. The charge of the emitted electron bunches can be changed by adjusting the laser energy with a remote controlled variable attenuator. The number of micro-pulses in a pulse train can be changed remotely from 1 to 800.

The previous laser system had a so-called “M-shape” temporal profile of maximum 24 ps FWHM pulse length with a dip in the middle, and with rise and fall times of 6–8 ps [22]. Beam dynamics simulations suggest that steepening the edges of the laser pulse decreases the contribution from the large slice emittances in the head and tail of the electron bunch emitted from the photocathode and therefore limits the growth of the projected emittance due to the space-charge force [21]. Simulation results reveal that a decrease of the rise and fall time from 6 ps to 2 ps leads to a reduction of the transverse projected emittance of about 30% [22].

The new laser system was thus designed to allow faster rise and fall times of the longitudinal flat-top shape. A pulse shaper based on multicrystal birefringent filters in the new laser system can transform the initial Gaussian pulse shape into a temporal flat-top shape with rise and fall times as short as 2 ps and a maximum pulse length of 25 ps FWHM [20]. The length of the temporal profile can be adjusted in order to study the dependence of the electron beam properties on the laser pulse length. The temporal profile of the UV output pulses is measured with an optical sampling system using an optical cross-correlation technique. A single UV pulse train (>400 micro-pulses) is sampled with the IR sub-ps laser pulses of the oscillator. This allows a measurement of the longitudinal shape with a rate of 10 Hz. The obtained shape is in good agreement with those obtained with a single shot measurement of one micro pulse using a high resolution streak camera [23]. The resolution of the measured temporal shape of the laser pulses is better than 1 ps [20]. Laser temporal profiles used in the measurements mentioned in this paper were flat-top pulses with 20–25 ps FWHM and 2–4 ps rise and fall time. Fig. 2 shows an example of a measured temporal laser profile (blue) in comparison with the flat-top fit (red) for a pulse length of about 23 ps (FWHM) and rise and fall times of 2 ps.

The transverse laser spot size on the photocathode has an important impact on the transverse emittance. A set of remotely changeable circular beam shaping apertures of different sizes is used to select the central part of a wide Gaussian transverse profile of the laser beam in order to adjust the transverse laser spot size at the cathode. First, the laser beam is imaged onto the beam shaping aperture and then the cut beam is imaged onto the cathode. This aims to result in a round and flat-top transverse shape of the laser beam. The beam shaping apertures have diameter sizes from 0.2 to 3 mm corresponding to laser rms spot sizes at the cathode from 0.05 to 0.44 mm. The laser transverse profile is monitored using a so-called virtual cathode system. It consists of a beam splitter for reflecting the laser light towards a CCD camera which is located at the cathode-equivalent position. An example of the transverse distribution of the photocathode laser pulse is shown in Fig. 3. The laser intensity profiles across a line cut through the center of the laser spot for both horizontal and vertical plane are shown in Fig. 4. For this example, the laser spot is quite symmetric and the laser intensity is flat at the central part of the transverse distribution. However, some inhomogeneity of the distribution is observed at the boundary of the spot. The homogeneity of the laser transverse distribution for various beam shaping apertures depends on the selected part of the initial Gaussian transverse profile of the laser beam. In emittance optimizations, the effort to achieve the symmetric and homogenous transverse laser distribution has been performed.

2.3. Tuning of photo-injector

The emittance measurement quality depends strongly on the machine conditions and the electron beam characteristics. Therefore, a proper setup of the photo-injector is required prior to taking data with a procedure as described in detail in Ref. [11]. The preparation starts with a beam-based alignment of the laser position at the cathode and the main solenoid magnet, with the goal to align the laser spot and the main gun solenoid such that the electron beam is emitted from the cathode on the axis of the
Electron beams exiting from the RF-gun still remain in the space charge dominated regime which the transverse emittance can increase while the beams are propagated along the beam transport line. In order to conserve low emittance beams a 9-cell normal conducting TESLA type RF cavity was used to achieve higher beam energy where space charge effects are reduced. This booster cavity was retained from the 2007 setup [11], but its position was shifted by 0.6 m downstream in order to fulfill the invariant envelope matching conditions for delivering the smallest projected emittance corresponding to a peak accelerating gradient of 60 MV/m at the photocathode. Standard operation conditions of the booster cavity for a bunch charge of 1 nC were 10 Hz repetition rate, 50 μs RF pulse length and about 2.5 MW RF peak power, resulting in a final momentum of ~14.8 MeV/c.

The performance of the booster cavity was strongly limited by the available cooling system. For the operation with a bunch charge lower than 1 nC, many micro-bunches in the train were used, which required a longer RF pulse length for the booster cavity and therefore forced a lower booster gradient. The booster gradient was adjusted to have a final momentum of ~12.6 MeV/c for emittance measurements of bunch charges below 1 nC. An RF pulse length of 100 μs and RF peak power of about 1.3 MW were used.

3. Emittance measurement method

3.1. Instruments and measurement procedure

The transverse phase space distribution and the transverse projected emittance of the electron beam are measured using a single slit scan technique [11,24]. With this technique a space-charge dominated electron beam is converted into a set of emittance dominated beamlets, which are used to measure the local beam divergence [25]. The Emittance Measurement SYstem (EMSY) consists of two orthogonal actuators for horizontal and vertical movements. On each actuator, a YAG or an OTR screen is mounted for measuring the beam transverse distribution. 10- and 50-μm opening slit masks are mounted on each actuator and are used to transversely cut the beam into thin slices. Stepping motors are employed to move and adjust the spatial position and angular orientation of the actuators with respect to the beam. A spatial position accuracy of about 1 μm is obtained. The slit mask angle can be precisely adjusted for an optimum angular acceptance of the system with a precision of about 2 mrad per step.

Three EMSY stations were installed in the setup as shown in Fig. 1. The first emittance measurement system (EMSY1) behind the exit of the booster cavity is used for standard emittance measurements. It is located 5.74 m downstream the photocathode, because this position is the expected minimum emittance location obtained from beam dynamics simulations. A YAG powder-coated screen placed at 90° to the beam axis with subsequent mirror at 45° is used to measure the beam transverse size at EMSY1. A 10-μm slit mask is used following a suggestion from detailed optimizations in Refs. [24,26], which combined the influence of the space-charge forces, the error from the initial beamlet transverse size, and the resolution in the measurement of...
the beamlet divergence. The local divergence is estimated by measuring the profiles of the beamlets created by the slit on a YAG screen at an observation station with the distance $L_d$ downstream of the EMSY station. The bucking solenoid current is set to compensate the residual magnetic field at the photocathode for each main solenoid current. Since the single slit scan technique is not a single shot measurement, uncertainties from the machine instability are included in the slit scan data.

In the emittance measurement procedure performed at PITZ prior to the run period in 2008–2009, a single slit scan was carried out with 200 μm step size for each solenoid current, corresponding to about 20–30 beamlets for each transverse plane. At the optimum solenoid current, where the minimum emittance value was found, a fine slit scan was repeated with 50 μm step size resulting in about 100 beamlets for each plane. The measurement time for a fine scan was ~30 min.

In the 2008–2009 run period, the emittance measurement procedure was improved to accelerate the slit scan and the data taking: the slit is continuously moved through the beam with constant speed within the scan limit. A typical speed is about 0.1–0.5 mm per second. The images at the beamlet observation screen are recorded with a CCD camera at 10 Hz repetition rate. The slit scan measurement and analysis are semiautomatically performed with the help of a client application called Emittance Measurement Wizard (EMWiz) [27]. The program combines an acquisition tool for performing slit scans and recording the beam spot or beamlet image and a postprocessing tool for analyzing the measured transverse phase space. The scan and data acquisition time for one measurement with a number of beamlets comparable to the old procedure is ~20 s now. Since the measurement time is greatly reduced, several slit scans for a certain machine setting are now possible within a given time. This allows to distinguish between uncertainties of the measurement procedure and effects of jitter and drifts in the machine parameters.

In addition, more accurate criteria for the beamlet image quality using the full dynamic range of the CCD camera with 12 effective bits were defined. The number of laser pulses was adjusted to have a good beamlet intensity at the observation screen. This procedure includes checking pixel saturation during the scan and taking the statistics over all pixels in all beamlets. The measurement procedure was done in such a way that the low intensity tails of the measured phase-space distribution were included in the analysis in order to obtain a 100% rms emittance value.

3.2. Emittance data analysis

The single slit scan technique is used to measure the phase-space distribution of the electron beam at the slit position by measuring the projection of the beamlet images on the observation screen at some distance downstream of the slit location. As an example in Fig. 6, the slit positions are plotted at the horizontal axis ($x$) and the corresponding projection of the beamlet profiles characterizing the local divergence $\chi_i$ are binned as the vertical column at each slit position. The index $i$ corresponds to the specific slit position and runs from 1 to the total number of measured beamlets. This divergence value is related to the rms transverse momentum spread $\sqrt{\langle p_x^2 \rangle}$ by $\chi \sim p_x / \langle p_x \rangle$ (if $\langle p_x \rangle > p_x$), where $\langle p_x \rangle$ is the mean longitudinal momentum.

The transverse emittance is proportional to the area of the phase-space ellipse and the normalized projected rms emittance can be calculated according to the following formula:

$$\tilde{\epsilon}_{nA} = \beta \gamma \sqrt{\langle x'^2 \rangle \langle x'^2 \rangle - \langle x' \rangle^2}.$$  \hspace{1cm} (1)

The factor $\beta \gamma$ is defined from the measured beam momentum by using a spectrometer dipole magnet and a corresponding screen station in the dispersive section, where $\beta$ is the average electron velocity normalized to the speed of light and $\gamma$ is the relativistic Lorentz factor. The transverse rms beam size ($\sqrt{\langle x'^2 \rangle}$) and the beam divergence ($\sqrt{\langle x'^2 \rangle}$) are obtained by analyzing the projection of the $(x,x')$ phase-space distribution from the slit scan measurement.
and \(\langle xx' \rangle\) is the covariance term where the relative position of the beamlet on the observation screen with respect to the corresponding slit position is taken into account.

From experimental experience, the measured transverse rms beam size from the measurement of beamlets at the observation screen (i.e. projection of the phase-space distribution in Fig. 6 on the horizontal axis) is smaller than the measured beam transverse size at the EMSY screen. This is caused by signal losses at the tails of the beam distribution due to the restricted sensitivity of the beamlet observation screen and the optical system. Losses in the tails of the phase-space distribution would result in an under-estimation of the measured emittance value. To correct for low intensity signals in the tails of the phase-space distribution a correction factor \(\sigma_x/\sqrt{\langle x^2 \rangle}\) is introduced. It is determined as the ratio of the total rms beam size measured with the full beam on the EMSY screen where the slit scan is performed (\(\sigma_x\)) and the beam size estimated from the phase space obtained from the slit scan on the observation screen \(\sqrt{\langle x^2 \rangle}\). Applying this correction factor to the standard normalized emittance formula in Eq. (1), we obtain the so-called corrected normalized projected emittance formula:

\[
\varepsilon_{nx} = \beta_p \frac{\sigma_x}{\sqrt{\langle x^2 \rangle}} \sqrt{\langle x^2 \rangle \langle y^2 \rangle - \langle xx' \rangle^2}. \tag{2}
\]

This correction is identical the same as if the linear correlation is removed from the measured phase-space distribution and the resulting rms divergence is multiplied by the rms beam size \(\sigma_x\) measured with the whole beam at the slit location. Emittance analysis using the formula in Eq. (2) results in a conservative emittance estimation because the correction factor \(\sigma_x/\sqrt{\langle x^2 \rangle}\) is almost always larger than 1. For all measurements mentioned in this paper the correction factor value is between 0.9 and 2.6. The fact that the correction factor in some exceptional cases is smaller than 1 can be correlated to machine instabilities during the time when the slit is scanning over the full scan span and the beamlet images are taken. For the minimum emittance points in the solenoid scans for the four different charge levels (1, 0.5, 0.25, 0.1 nC) the correction factor is between 0.98 and 1.32 and its average is 1.12 ± 0.04. Since we have taken maximum effort to not cut any signal from the measured phase-space distribution in the analysis and we calculate real rms values (no fits are applied) we call our results “100% rms values”.

4. Emittance optimization

4.1. Operation with bunch charge of 1 nC

Measurements of the transverse projected emittance for a nominal bunch charge of 1 nC were performed at the first emittance measurement system station (EMSY1), 5.74 m downstream the photocathode. In order to study the emittance dependence on the transverse laser size at the cathode, rms laser spot sizes of 0.26, 0.29, 0.38 and 0.44 mm were applied. For each laser spot size single slit measurements were carried out as a function of the main solenoid current around the minimum beam size at the YAG screen of EMSY1. The gun RF phase was also varied to investigate its influence on the measured emittance. Experimental results showed that a gun phase of \(+6^\circ\) from MMMG phase towards on-crest delivered the minimum measured emittance value. The field gradient at the photocathode at this phase is about 44 MV/m. The measured mean momentum corresponding to this phase was 6.67 MeV/c with a spread of about 40 keV/c. During these measurements the booster RF phase was set to be at the MMMG phase, while the gradient was set to the maximum accessible value allowed by the limit of the water cooling system. This results in a mean momentum of 14.7 MeV/c with a spread of about 150 keV/c.

The measured transverse projected emittance and rms beam size as a function of the main solenoid current for an rms laser spot size at the cathode of 0.38 mm and a gun RF phase of \(+6^\circ\) from the phase of MMMG are shown in Fig. 6. The geometric mean emittance value \((\varepsilon_{nxy})\) is defined as \(\varepsilon_{nxy} = \sqrt{\varepsilon_x \varepsilon_y}\), where \(\varepsilon_x\) and \(\varepsilon_y\) are the horizontal and the vertical projected normalized rms emittance. In the following parts of this paper, the index “n” will be suppressed for simplicity although only normalized quantities will be reported. The geometric mean rms laser spot size \((\sigma_{lx})\) is derived from \(\sigma_{lx} = \sqrt{\sigma_x^2 \sigma_y^2}\), where \(\sigma_x\) and \(\sigma_y\) are the horizontal and the vertical rms beam size, respectively. As can be seen in Fig. 7, the minimum measured geometric mean emittance was obtained at a main solenoid current of 387 A corresponding to a solenoid peak field of 228 mT. Typically, the optimum main solenoid current, which delivers minimum measured emittance for a bunch charge of 1 nC, is found 2–5 A above the focusing point, it is 3 A in this case. At this minimum, a geometric mean emittance was measured to be 0.99 mm mrad.

Statistical measurements for the same machine setting but with an improved beam steering condition through the booster cavity were performed at the optimum main solenoid current (387 A) obtained from the solenoid scan measurement. The minimum measured normalized rms emittance was 0.72 ± 0.01 mm mrad in the horizontal plane and 1.09 ± 0.02 mm mrad in the vertical plane. This corresponds to a geometric mean emittance of 0.89 ± 0.01 mm mrad. The statistical uncertainty given in the results were obtained from four measurement sets which were taken in a time period of ~30 min. However, this small emittance value could not reproducibly be measured in the next shift due to the instabilities of the machine, e.g. gun RF phase. Detailed studies concerning this issue are discussed in Section 4.4. Reconstructed phase-space distributions from one set of the statistical measurements are shown in Fig. 9 for both transverse directions. For sufficient beamlet signal intensity, 27 and 17 electron bunches were used for the measurements of the horizontal and vertical phase space, respectively. A summary of machine and beam parameters for the operation conditions that lead to the smallest measured emittance for the nominal bunch charge of 1 nC are listed in Table 1.

![Fig. 7. Measured normalized projected emittance (left axis) and rms beam size (right axis) as a function of main solenoid current for a measured rms laser spot size at the cathode of 0.38 mm. The minimum emittance was obtained at a main solenoid current of 387 A corresponding to the solenoid peak field of 228 mT.](image-url)
beams. This in general leads to a bigger beam size in the vertical plane and consequently to a bigger emittance. This is not the case for a small rms laser spot size (0.26 mm), pointing to an effect of high space charge intensity at the cathode during charge emission for small laser spot size at the cathode. It is important to be noted here that the transverse shape of the photocathode laser spot and the beam after exiting the RF-gun were round. The beams with asymmetric and tilted transverse shape were observed after the booster acceleration.

4.2. Operation with bunch charges of 0.5, 0.25 and 0.1 nC

Optimization of the transverse projected emittance was also performed for electron bunch charges of 0.5, 0.25, and 0.1 nC. Gun and booster RF phases of $+6^\circ$ and 0$^\circ$ from the phase of M3M3G towards on-crest were used. The gun gradient was set to be at the maximum available value of ~60 MV/m at the photocathode. Due to the lower charge, more laser pulses were used to adjust the intensity of the beamlet signal at the observation screen. This required a longer RF pulse length for the gun and the booster cavity. In the measurements for these three bunch charges the booster cavity was operated with an RF pulse length of 100 $\mu$s. Since a limitation in the capacity of the water cooling system restricted the operation of the booster cavity with long RF pulse trains at high acceleration, a lower booster gradient was used and resulted in a final beam momentum of about 12.6 MeV/c.

The measurements were performed with the same procedure and at the same measurement location as in the case of 1 nC. The dependence of the transverse projected emittance on the rms laser spot size at the cathode was also studied. Similar to the case of 1 nC, the vertical emittance value was measured to be larger than the horizontal ones. This relation is inverted when the rms laser spot size is smaller than 0.26, 0.21 and 0.15 mm for a charge of 0.5, 0.25 and 0.1 nC, respectively. The possible reason for this phenomenon was discussed in Section 4.1. The measured geometric mean emittance as a function of the rms laser spot size at the cathode for a bunch charge of 1 nC. Each data point was obtained from the optimization with the solenoid scan. The gun and the booster RF phases were $+6^\circ$ and 0$^\circ$ from the phase of M3M3G towards on-crest, correspondingly.

\begin{figure}
\centering
\includegraphics[width=0.8\textwidth]{figure9}
\caption{Measured normalized projected emittance as a function of the rms laser spot size at the cathode for a bunch charge of 1 nC. Each data point was obtained from the optimization with the solenoid scan. The gun and the booster RF phases are $+6^\circ$ and 0$^\circ$ from the phase of M3M3G towards on-crest, correspondingly.}
\end{figure}

Results of emittance optimization for different laser spot sizes for fixed gradients and RF phases of the gun and the booster cavity are shown in Fig. 9. The minimum emittance was obtained for an rms laser spot size of 0.38 mm. As can be seen in Figs. 7–9 there is an asymmetry in the measured horizontal and vertical emittance values. One possible reason is an asymmetric shape of the booster cavity at the RF waveguide input location. Asymmetric electromagnetic fields due to an opening in the vertical wall of the booster cavity can introduce a vertical kick to the beams.

\begin{table}
\centering
\begin{tabular}{|l|l|}
\hline
Parameter & Value \\
\hline
Geometrical rms laser spot size & 0.38 mm \\
Laser temporal length (FWHM) & 23.1 ps \\
Laser temporal rise-fall-time & 2.1/2.4 ps \\
Gun RF phase & $+6^\circ$ \\
Booster RF phase & 0$^\circ$ \\
Beam momentum after the gun & 6.67 MeV/c \\
Final beam momentum & 14.8 MeV/c \\
Main solenoid current & 387 A \\
Geometric mean rms beam spot size & 0.60 mm \\
Horizontal emittance & 0.72 $\pm$ 0.01 mm mrad \\
Vertical emittance & 1.09 $\pm$ 0.02 mm mrad \\
Geometric mean emittance & 0.89 $\pm$ 0.01 mm mrad \\
\hline
\end{tabular}
\caption{Optimum machine and beam parameters and measured results to obtain the minimum normalized transverse projected emittance of the electron beam with a bunch charge of 1 nC.}
\end{table}
was kept at the maximum acceleration phase. For each data point the solenoid phase was at the cathode for a charge of 1, 0.5, 0.25 and 0.1 nC per bunch. The gun RF phase at a given position within the RF pulse train were observed [29]. Therefore, stability measurements were performed for the nominal bunch charge of 1 nC with the machine conditions and beam characteristics listed in Table 3.

Machine and beam parameters in Table 3 are about the same as in the case of minimum emittance except the laser pulse length was about 4 ps shorter as well as the rise and fall time were longer due to the damage of some crystals in the laser pulse shaper. This resulted in emittance values larger than for the optimum case as discussed in Section 4.1. A standard deviation of the geometric mean emittance fluctuation of about 5% (rms) was observed for a 0.25 nC bunch charge, where a normalized projected emittance of about 0.4 mm mrad is obtained. This emittance value is comparable to the value obtained at LCLS [28], where an FEL operation with a wavelength of 0.15 nm was demonstrated.

### Table 2

<table>
<thead>
<tr>
<th>Parameter</th>
<th>0.5 nC</th>
<th>0.25 nC</th>
<th>0.1 nC</th>
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<tr>
<td>( \sigma_x ) (mm)</td>
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<td>( \tau ) (ps)</td>
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<tr>
<td>( t_s ) (ps)</td>
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<td>2.4</td>
<td>2.8</td>
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<tr>
<td>( t_f ) (ps)</td>
<td>3.5</td>
<td>3.1</td>
<td>4.6</td>
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<tr>
<td>( l_{\text{max}} ) (A)</td>
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<td>384</td>
<td>382</td>
</tr>
<tr>
<td>( \sigma_y ) (mm mrad)</td>
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<tr>
<td>( \varepsilon_x ) (mm mrad)</td>
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</tr>
<tr>
<td>( \varepsilon_y ) (mm mrad)</td>
<td>0.64</td>
<td>0.47</td>
<td>0.33</td>
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</table>

The solenoid scan for each laser spot size was also performed. The measured geometric mean emittance and the rms beam size as a function of main solenoid currents for a bunch charge of 0.5, 0.25 and 0.1 nC are illustrated in Fig. 13. An example of one of the interesting cases is for 0.25 nC with 5% charge cut, where a normalized projected emittance of about 0.4 mm mrad is obtained. This emittance value is comparable to the value obtained at LCLS [28], where an FEL operation with a wavelength of 0.15 nm was demonstrated.

### 4.4. Stability of emittance measurement

During the emittance measurements, strong fluctuations of the gun RF phase at a given position within the RF pulse train were observed [29]. Therefore, stability measurements were performed for the nominal bunch charge of 1 nC with the machine conditions and beam characteristics listed in Table 3.

Machine and beam parameters in Table 3 are about the same as in the case of minimum emittance except the laser pulse length was about 4 ps shorter as well as the rise and fall time were longer due to the damage of some crystals in the laser pulse shaper. This resulted in emittance values larger than for the optimum case as discussed in Section 4.1. A standard deviation of the geometric mean emittance fluctuation of about 5% (rms) was observed for a measurement time of about 3 h (Fig. 14). The rms beam size jitter was measured to be about 4%. Long term stability measurements were performed over 4 days and the results are shown in Fig. 15. The rms deviation of the horizontal, vertical and geometric mean emittance is 6%, 8% and 5%, respectively.

The solenoid scan for each laser spot size was also performed. The measured geometric mean emittance and the rms beam size as a function of main solenoid current for the optimum rms laser spot sizes at the cathode are 0.26, 0.21 and 0.15 mm, respectively. Machine and beam parameters used in the measurements of a bunch charge of 0.5, 0.25 and 0.1 nC are listed in Table 2.

### 4.3. Emittance vs. charge cut

Since the particles in the low intensity tails of the transverse phase-space distribution do not contribute to the lasing process in short wavelength FELs but have a significant contribution to the 100% rms emittance they can be subsequently removed in the analysis procedure in order to obtain a kind of core emittance which is important for the FEL process. In addition the emittance as a function of the charge cut can be used to compare the PITZ results with other facilities where in general intrinsic cuts in the tails of the measured phase-space distributions are performed, e.g. by omitting the beamlets in the tails of the beam distribution when performing logger pot method or by fitting Gaussian distributions to the measurement during quadrupole scans.

A cut on the low intensity tails of the measured phase-space distribution to estimate the emittance as a function of the charge cut was performed. As an example the measured phase space distribution for 1 nC bunch charge was estimated by removing 10% of the total bunch charge from the lowest density regions in the measured phase-space distributions in Fig. 8 and the 90% charge intensity phase-space distributions are shown in Fig. 12. The result shows that a geometric mean emittance as small as 0.67 mm mrad is achieved.

The phase-space distribution of the minimum geometric mean emittance results are re-analyzed as a function of the charge cut in the tails of the phase-space distribution. The results for the bunch charges of 1, 0.5, 0.25 and 0.1 nC are illustrated in Fig. 13. An example of one of the interesting cases is for 0.25 nC with 5% charge cut, where a normalized projected emittance of about 0.4 mm mrad is obtained. This emittance value is comparable to the value obtained at LCLS [28], where an FEL operation with a wavelength of 0.15 nm was demonstrated.
5. Comparison of measurements with simulations

Beam dynamics simulations using the space-charge particle tracking code ASTRA [30] were performed to study the dependence of the emittance on the laser spot size at the cathode as well as gun phase, solenoid magnetic field, booster phase and booster gradient. Simulation studies included machine and beam parameters according to the experimental conditions. The laser flat-top temporal length as well as the rise and fall time was set to

\[ \text{emittance (mm} \cdot \text{mrad)} \]

<table>
<thead>
<tr>
<th>Parameter</th>
<th>Value</th>
</tr>
</thead>
<tbody>
<tr>
<td>Charge per bunch</td>
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</tr>
<tr>
<td>Laser pulse length (FWHM)</td>
<td>18.9 ps</td>
</tr>
<tr>
<td>Laser temporal rise-/fall-time</td>
<td>3.0/3.2 ps</td>
</tr>
<tr>
<td>Laser rms spot size at the cathode</td>
<td>0.38 mm</td>
</tr>
<tr>
<td>Mean momentum</td>
<td>14.4 MeV/c</td>
</tr>
<tr>
<td>Main solenoid current</td>
<td>384 A</td>
</tr>
</tbody>
</table>

Fig. 13. Minimum geometric mean emittance ($\langle \varepsilon \rangle$) as a function of a charge cut starting from the lowest density tails in the phase-space distribution for a bunch charge of 1, 0.5, 0.25 and 0.1 nC. The 100% emittance values reported here are for a charge cut 0% (no charge cut).

Fig. 12. Measured horizontal (top) and vertical (bottom) phase-space distributions for 90% charge intensity for a bunch charge of 1 nC. A geometric mean emittance ($\langle \varepsilon \rangle$) of 0.67 mm.mrad is obtained. Machine conditions and beam characteristics are the same as in the measurements of the phase space distributions in Fig. 8.

Fig. 14. Stability check of the measured emittance (left axis) and rms beam size (right axis) for the measurement time of about 3 h. The rms standard deviation of the geometric mean emittance and the beam size are 5% and 4%, respectively. The measurements were performed for a bunch charge of 1 nC with the parameters in Table 3.

Fig. 15. Fluctuations of the measured emittance for an operation time over 4 days. The measurements were performed for a bunch charge of 1 nC with the parameters in Table 3. The rms standard deviation of the fluctuation of the geometric mean emittance is \( \sim 5\% \).
be the measured values for each bunch charge as shown in Tables 1 and 2. The simulated accelerating gradients at the cathode and in the booster cavity were adjusted to achieve the same maximum mean momenta as in the measurements. The gun and the booster phases are defined such that zero degree corresponds to the phase of MMMG.

As an example, a series of simulations were performed to find the optimum parameters for the case of an electron beam with a bunch charge of 1 nC. A temporal laser profile of flat-top shape with 23 ps FWHM pulse length and 2 ps rise and fall time, as in the measured temporal profile in Fig. 2, was used. An RF-gun field ratio (cathode to center of the full-cell) of 1.05, as in the measured field profile [17], was applied. Twenty thousand macro-particles were tracked in the ASTRA simulations, and 60 radial grid ring and 100 longitudinal grid were used for the space charge calculation. A theoretical initial electron kinetic energy of 0.55 eV were applied [31]. Some approximations were included in the simulations discussed in this paper. An additional emitted charge and a modification of the bunch due to Schottky-like effects is not taken into account. The transverse laser distribution was assumed to be uniform and not to be modified by inhomogeneous cathode emission.

The simulated mean momentum and momentum spread as a function of the maximum accelerating gradient at the cathode are shown in Fig. 16. The solenoid field was chosen to be 226.2 mT, which allows all electrons to be extracted and accelerated out of the gun cavity with good focusing. The results in Fig. 16 suggest that a maximum gradient at the photocathode of 58.6 MV/m delivers an electron bunch with a mean momentum of 6.68 MeV/c at the MMMG phase as in the measurement. In the next step, the final mean momentum was tuned by varying the booster gradient and the result shows that in order to achieve a final beam momentum of 14.8 MeV/c at the MMMG phase as in the measurement a booster gradient of 15 MV/m should be used. By following the simulation results, we used the gun and the booster gradients of 58.6 MV/m and 15 MV/m, respectively, in all simulations for a bunch charge of 1 nC.

The dependence of the projected emittance on the gun RF phase was studied with results shown in Fig. 17. The rms laser spot size at the cathode used in this simulation was 0.41 mm. The booster RF phase was kept at the maximum acceleration phase. The solenoid peak field was varied to obtain a minimum emittance value for each gun phase. The result in Fig. 17 suggests that the smallest emittance value is obtained with the gun phase of +0.5° from the phase of MMMG towards on-crest whereas +6° was experimentally found. At the gun phase of +0.5° the field gradient at the photocathode is 40 MV/m.

Similar to the simulations of the gun RF phase, the emittance dependence on the booster RF phase was investigated and the results are illustrated in Fig. 18. The gun phase was set to be at +0.5° from the MMMG phase and the solenoid field was scanned to deliver the minimum emittance value. Simulation results show that the minimum projected emittance is found at a booster RF phase of +5° from the phase of MMMG towards on-crest. However, at this phase the correlated momentum spread increases from 62 keV/c to 101 keV/c. Since steering magnets are needed to be used in the PITZ beamline in order to transport the beam through the center of different measurement devices the larger momentum spread will lead to larger spot sizes and consequently larger emittance values. Therefore a beam with smaller momentum spread is preferable for the photo-injector. The results depicted in Fig. 18 show that the projected emittance depends only weakly on the booster phase around the MMMG phase (0°), which was used in the measurement cases. The emittance value is only 0.08% smaller when the booster phase is at +5° from the MMMG phase but the momentum spread
becomes significantly larger by 63.2%. In all simulations (Figs. 16–18), the optimum rms laser spot size at the cathode of 0.41 mm was used (see next paragraph).

The dependence of the emittance on the rms laser spot size at the cathode was also studied. Simulation predictions in Fig. 19 show that an rms laser spot size at the cathode of 0.41 mm delivers the minimum emittance value of 0.64 mm mrad at the considered emittance measurement station, EMSY1 (5.74 m downstream the photocathode). Unfortunately, the same laser spot size could not be produced experimentally due to the limitation of available apertures in the laser system in the described setup. However, the emittance value increases only 1.4–2.0% for the experimentally available rms laser spot sizes of 30 µm smaller and larger than 0.41 mm. The emittance measurement result for a bunch charge of 1 nC shows that the minimum measured projected emittance was found at an rms laser spot size of 0.38 mm, which is close to the expectation from the simulation.

The simulated dependence of the emittance on the peak solenoid field is shown in Fig. 20. In this simulation, the optimum rms laser spot size of 0.41 mm was used, the gun and the booster RF phases were at +0.5° and 0° from the phase of MMMG. The optimization results show that the minimum emittance value was obtained with a peak solenoid field of 226.2 mT. This solenoid field corresponds to a main solenoid current of 384 A, whereas the smallest beam size is obtained at 379 A. In the measurement, the minimum emittance point was obtained at a main solenoid current of 387 A, which means there is a discrepancy of 3 A (corresponding to a solenoid peak field of 2 mT) between the measurement and the simulation. A part of the discrepancy can be related to a possible error in the magnetic field calibration of the solenoid magnets.

The dependence of the emittance on the booster cavity position and gradient were simulated in order to study the emittance conservation using a post-acceleration cavity. In both simulations, a gun phase of +0.5° from the MMMG phase and the rms laser spot size at the cathode of 0.41 mm, which yield the minimum projected emittance value, were used. The booster RF phase was set at the phase of MMMG. The simulations show that the minimum emittance can be conserved by locating a booster cavity at the position of the beam envelope waist. It means that the starting point of the RF field of the TESLA booster cavity should be at 3.64 m downstream the photocathode. According to this simulation result, the position of the booster cavity was then shifted by 0.6 m downstream as mentioned in Section 2.3.

Simulations of the projected emittance and the momentum of the electron beam as a function of the booster gradient were performed and the results are shown in Fig. 21. The solenoid peak field was scanned to obtain the minimum emittance value for each simulation point. It is clearly seen that higher booster gradients deliver smaller projected emittance values. However, the rate of emittance reduction slows down for larger booster gradients.

Fig. 22 shows the simulated evolution of the normalized projected emittance and the rms beam size along the beam line (z-position). The minimum normalized projected emittance at the position of the EMSY1 station, 5.74 m downstream the photocathode, is expected to be 0.64 mm mrad. Machine and beam parameters used in the beam dynamics simulations to define this minimum emittance are summarized in Table 4. The emittance value stays almost constant for z-positions between about 5.5 and 6.1 m. Then, it increases almost linearly proportional to the longitudinal distance. This fact shows that the mean momentum...
of 14.8 MeV/c is not enough for suppressing the space-charge force. A higher final beam momentum by using a higher gradient or a longer accelerating cavity is thus required in order to conserve the transverse projected emittance. Simulation studies of the influence of different machine and beam parameters on the emittance were also performed for the bunch charges of 0.5, 0.25 and 0.1 nC. The maximum accelerating gradient at the cathode of 58.6 MeV/c was applied in order to obtain a beam mean momentum of 6.68 MeV/c at the MMMG phase after the gun acceleration. The simulated accelerating gradient of the booster cavity was adjusted to be 10.4 MV/m to deliver a final mean momentum of 12.3 MeV/c, which was used in the measurements. According to simulation results in Fig. 19 the emittance value increases by 13.3% when reducing the booster gradient from 15 MV/m (used for the 1 nC case) to this value 10.4 MV/m.

The rms laser spot sizes at the cathode in these simulations included the values resulting from available beam shaping apertures used in the measurements. In case of small laser spot sizes at the cathode the space charge effect dominates the electron emission process. Simulations of the emitted charge per bunch and the projected emittance as a function of the laser spot size at the cathode were performed for the desired bunch charges of 1, 0.5, 0.25 and 0.1 nC and the results are shown in Figs. 23 and 24. The Schottky-like effects were not included in the simulations. The results reveal that by considering only the photoemission process due to laser pulses hitting the cathode, the desired bunch charge of 1, 0.5, 0.25 and 0.1 nC cannot be produced by using an rms laser spot size smaller than 0.36, 0.24, 0.15 and 0.10 mm, respectively.

Simulation results in Fig. 24 suggest that the minimum emittance values should be found at an rms laser spot size of 0.41, 0.29, 0.21 and 0.12 mm for a bunch charge of 1, 0.5, 0.25 and 0.1 nC, respectively. Unfortunately, the same laser spot size could not be produced in the experiment due to the limitation of available apertures in the measurement cases. Further investigation will be performed in the future upgraded PITZ setup using a remote control of diaphragm beam shaping aperture enabling fine tuning of the aperture size. A summary of the measured and simulated optimum rms laser spot sizes at the cathode for minimum transverse projected emittance values are shown in Table 5.

Measured and simulated normalized projected emittances as a function of the bunch charge are shown in Fig. 25. In the simulations, rms laser spot sizes at the cathode of 0.38, 0.26, 0.21 and 0.15 mm were used for the bunch charges of 1, 0.5, 0.25 and 0.1 nC, respectively. In the simulation case, the gun RF phase was optimized to deliver minimum projected emittance for each bunch charge. The measured main solenoid current and the simulated peak solenoid field were varied to yield the smallest emittance points. In the measurement case, the emittance value of each point is the geometric mean of the normalized projected
emittance for the two transverse planes. The gun RF phase during the measurements was +6° from the phase of MMMG towards on-crest. In both measurement and simulation, the booster RF phase of MMMG was used.

Comparison of measurement results with the results from beam dynamics simulations shows that the measured projected emittances for the four bunch charges are larger than the simulation values. One part of the mismatch could be due to a large fluctuation of the RF-gun phase for a given bunch in the train and over the pulse train. This instability is considered to be the source of fluctuations of the measured electron beam size and emittance [29]. These fluctuations can result in a jitter of beam position, beam momentum and phase space distribution. Furthermore, the emittance measurement using a single slit scan technique is not a single shot measurement and the procedure even involves pulse trains of varying lengths for the beamlet intensity integration. Therefore the gun phase jittering will cause a smearing of the phase space distributions and results in larger measured emittances. The gun RF phase jitter also results in an uncertainty of the optimum gun phase condition.

Simulations of the influence of a gun phase jitter on the beam size and emittance were performed by overlapping the phase space distributions for different gun phases around the minimum emittance phase. Then, the rms beam size and the emittance were calculated from the overlapped distributions. The simulation results for a bunch charge of 1 nC are presented in Fig. 26 and show that emittance and beam size increase significantly for larger gun phase jitter. For a phase jitter of ±6° peak-to-peak, the emittance increases by 30.5%, corresponding to an emittance value of 0.84 mm mrad, which is close to the value obtained from the measurement (0.89 mm mrad).

Fig. 25. Simulated and measured normalized projected emittance as a function of the bunch charge. Machine and beam conditions are described in the text.

Table 5

<table>
<thead>
<tr>
<th>Parameter</th>
<th>1 nC</th>
<th>0.5 nC</th>
<th>0.25 nC</th>
<th>0.1 nC</th>
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<tbody>
<tr>
<td>σx (mm)</td>
<td>0.38</td>
<td>0.26</td>
<td>0.21</td>
<td>0.15</td>
</tr>
<tr>
<td>σy (mm)</td>
<td>0.41</td>
<td>0.29</td>
<td>0.21</td>
<td>0.12</td>
</tr>
<tr>
<td>σxy (mm mrad)</td>
<td>0.89</td>
<td>0.64</td>
<td>0.47</td>
<td>0.33</td>
</tr>
<tr>
<td>ε (mm mrad)</td>
<td>0.64</td>
<td>0.40</td>
<td>0.25</td>
<td>0.16</td>
</tr>
</tbody>
</table>

Fig. 26. Simulated emittance and beam size increase due to gun phase jittering (peak-to-peak) for a charge of 1 nC per bunch. Machine and beam parameters used in this simulation are the same as for the simulation in Fig. 15.

A second source of discrepancy could be due to the thermal emittance contribution. The experimentally estimated thermal emittance is about 1.5 times higher than the value expected from theory [32]. Therefore, the value of the initial kinetic energy of 0.55 eV assumed in the ASTRA simulations might be too small. Nevertheless the thermal emittance measurement is difficult and has a large error bar. A third source of the difference is probably due to the missing knowledge concerning the booster cavity field under the high RF power operation which was used in the simulations. Another source of discrepancy could happen for small laser spot sizes (as shown in Section 5) where the space charge dominates the electron emission process and Schottky-like effects play a significant role. This results in a charge production enhancement due to the presence of a high electric field at the cathode. The electric fields distort the potential barrier at the cathode surface resulting in a lower work function and a higher quantum efficiency of the cathode material. This effect can lead to a difference between the optimum laser spot size obtained from the measured and the simulated cases.

6. Conclusion and outlook

This paper described and discussed the optimization of the projected transverse emittance for the RF-gun prototype 4.2 and the machine setup at the photo-injector test facility at DESY, location Zeuthen (PITZ), in the run period 2008–2009. This gun cavity was operated with an accelerating gradient of about system. The RF wave was supplied by a 10-MW multibeam klystron via two equal waveguide arms, where each arm contained a directional coupler for measuring forward and reflected RF waves to control the feeding of the RF waves to the gun. A ceramic vacuum window was installed after each directional coupler. Then, a T-shape combiner was used to mix both RF waves and feed them into the gun cavity. Due to the absence of a directional coupler downstream of the T-combiner, the low level RF regulation could only use the vector sum built from forward and reflected RF powers measured in both arms. A working RF feedback was not available, therefore only feed forward was used. The possibility of cross-talk of signals from both directional couplers through the T-combiner under not well-defined resonance conditions of the gun cavity caused complications of the low level RF regulation and consequently large measured gun phase fluctuations between 10° and 15° (peak-to-peak) [29]. The jitter of the RF-gun phase complicates not only the emittance measurement but also the procedure for the machine setup, resulting in uncertainty in the definition of the gun RF phase and an increase in the measured emittance value.

6. Conclusion and outlook

This paper described and discussed the optimization of the projected transverse emittance for the RF-gun prototype 4.2 and the machine setup at the photo-injector test facility at DESY, location Zeuthen (PITZ), in the run period 2008–2009. This gun cavity was operated with an accelerating gradient of about
60 MV/m at the photocathode. A successful demonstration of the required RF parameters for the injector of the European XFEL was performed with an average RF power of 50 kW for a 700 μs long RF pulse of 7.1 MW peak power at 10 Hz repetition rate. The gun has been delivered to FLASH and is then in continuous operation since February 2010 [33].

The emittance of electron beams produced by using flat-top temporal laser pulses was measured for bunch charges of 1, 0.5, 0.25 and 0.1 nC. Small emittance values beyond the requirements of the European XFEL were achieved, especially for 1 nC bunch charge. A minimum rms geometric average normalized projected emittance of 0.89 ± 0.01 mm mrad was measured at 1 nC bunch charge. This value is obtained from the 100% rms phase-space distribution. If 10% of the charge is removed from the lowest density regions in the phase-space distribution, an rms normalized projected emittance of 0.67 mm mrad is achieved. Emissivity optimizations for bunch charges below 1 nC were also performed. The 100% rms geometric mean emittance of 0.64, 0.47 and 0.33 mm mrad were measured for the bunch charges of 0.5, 0.25 and 0.1 nC, respectively.

Beam dynamics simulations based on the measured machine conditions and beam characteristics were carried out. Some discrepancies of the measured values from the simulation results were observed. The RF-gun phase instabilities are considered to be the major source of the mismatch between measurement and simulation results. Further investigations will be continued in the next run period using newly installed RF-gun and booster cavities [34]. The gun phase stability is anticipated to be improved for the new gun cavity with a new 10-MW in-vacuum directional coupler installed downstream the T-combiner. Direct monitoring and control of the combined forward and reflected RF waves will allow an RF feedback control loop for the amplitude and phase stabilization in the new setup. A new Cut Disk Structure booster cavity will allow to accelerate the electrons to above 20 MeV with high stability and will be suitable for operation with long pulse trains due to an efficient cooling system. In addition, the field profile of this booster cavity is well known. Altogether these should lead to an improvement in the simulation knowledge and a more flexible booster operation.

Acknowledgments

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